

Supplementary to Stress induced delamination of suspended MoS₂ in aqueous environments

Michal Macha^{1*}, Mukeshchand Thakur¹, Aleksandra
Radenovic^{1*} and Sanjin Marion^{1,2*}

¹Ecole Polytechnique Federale de Lausanne (EPFL), Lausanne,
Switzerland.

²Current address: imec, Kapeldreef 75, B-3001 Leuven, Belgium.

*Corresponding author(s). E-mail(s): michal.macha@epfl.ch;
aleksandra.radenovic@epfl.ch; sanjin.marion@imec.be;

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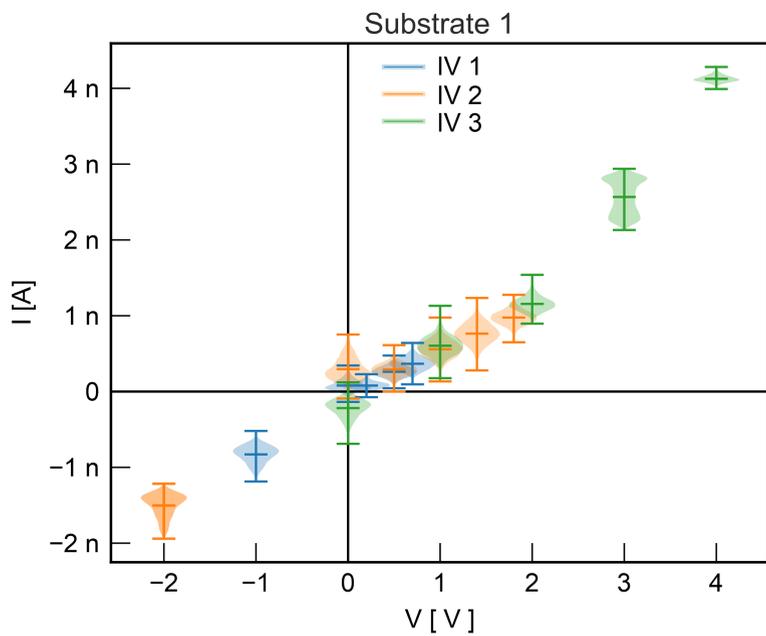


Fig. S1 IV measurement of delaminating MoS₂ Data extracted from ECR drilling procedure represented as an IV characteristic.

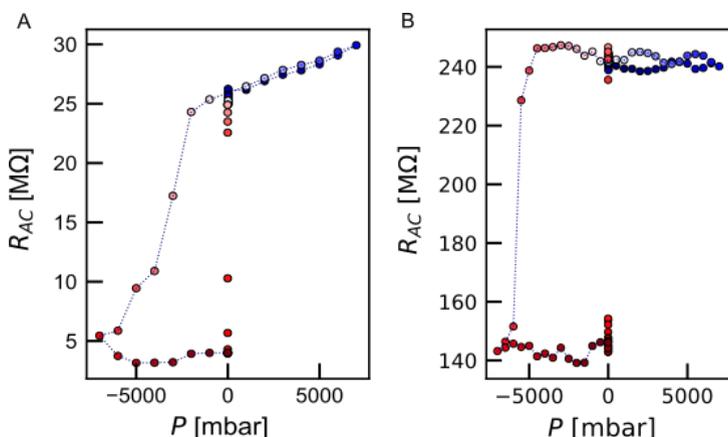


Fig. S2 Permanent, pressure-induced delamination. A pressure sweep measurement of delaminating MoS₂ film shown on two representative substrates (A) and (B). Membrane is swept with a pressure gradient (starting from 0 to 7 bar applied on the **frontside**, back to 0 and again to 7 bar applied on **backside** of the membrane and again back to 0 bar) under constant 100mV AC. Visible increase in ionic current occurs abruptly between 2 (A) and 5 (B) bar depending on the substrate. This indicates that the state of the membrane under no external applied force (voltage or pressure) has changed, supporting the scenario of irreversible delamination. Measurements were performed with the methodology described in the previous work using quasi-DC sinusoidal applied voltage[1, 2]

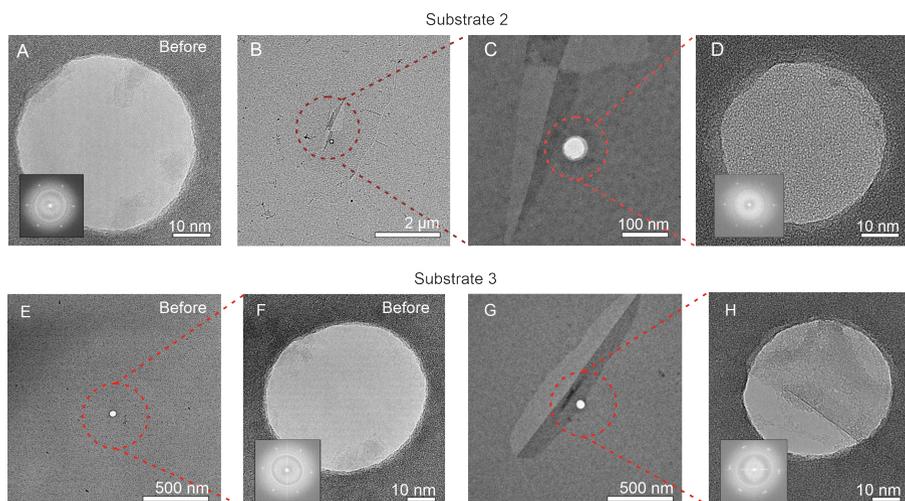


Fig. S3 HRTEM images of delaminating substrates before and after measurement. High resolution TEM images of substrate 2 before (A) and after (B-D) showing visible delaminated material near nanopore vicinity. Similarly, substrate 3 before (E-F) and after (G-H) images show delamination occurring around the same area. All images are supported with FFT images (insets) which confirm the presence of MoS₂.

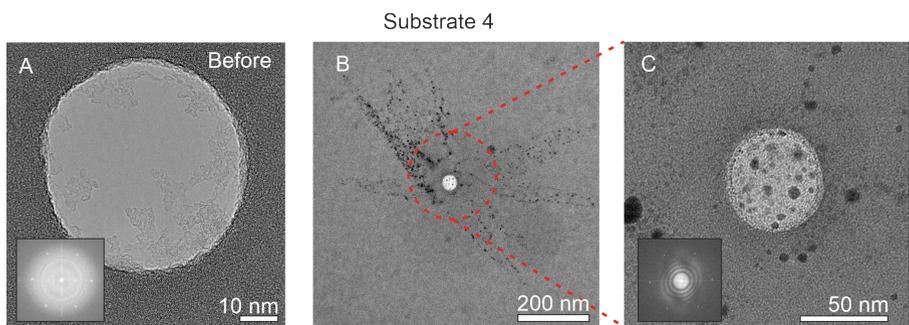


Fig. S4 HRTEM images of wrinkling substrate before and after measurement A high resolution TEM image of substrate 4 before (A) and after (B-C) nanofluidic measurements with MoS₂ remaining suspended over the membrane aperture. Insets represent FFT images with MoS₂ pattern, confirming its presence on the suspended area.

References

- [1] Marion, S., Macha, M., Davis, S.J., Chernev, A., Radenovic, A.: Wetting of nanopores probed with pressure. *Physical Chemistry Chemical Physics* **23**(8), 4975–4987 (2021). <https://doi.org/10.1039/D1CP00253H>
- [2] Davis, S.J., Macha, M., Chernev, A., Huang, D.M., Radenovic, A., Marion, S.: Pressure-Induced Enlargement and Ionic Current Rectification in Symmetric Nanopores. *Nano Letters* (2020).